## RŐSLER

... and it makes a difference!

Contact



After the ISF<sup>®</sup> process

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Contact us for further information or for a processing trial with your parts.

www.roslerusa.com



RŐSLER

finding a better way ...



**RÓSLER**<sup>®</sup> finding a better way ...

Before the ISF <sup>®</sup> process

## finding a better way



### Isotropic Superfinish (ISF<sup>®</sup>) Process

Chemically accelerated mass finishing achieves surface finishes as low as Ra = 0.02  $\mu$ m (Ra = 0.8  $\mu$ inch), Rz = 0.2  $\mu$ m (Rz = 8  $\mu$ inch)



### Two strong partners!

## How does the ISF<sup>®</sup> process work?

# ISF<sup>®</sup> surfaces improve your components' performance characteristics ...

The Rösler Company and REM Chemicals, Inc., leaders in vibratory mass finishing, and chemically accelerated surface finishing have combined their knowledge and experience to make the ISF<sup>®</sup> process available to a wider group of users.

# What applications is the ISF<sup>®</sup> process suitable for?

#### Materials

- ➡ Carbon steel and high-alloy steel
- ➡ Stainless steel
- ➡ Titanium, zinc, etc.

#### Typical applications

- → Aerospace and automotive gearbox components (mainly gears)
- ➡ Race car engine components (cam shafts, tappets, rocker arms)
- Bearing parts (races, rollers)
- ➡ Aerospace and power generation turbine components (blades, blisks, disks)
- ➡ Turned and milled precision components
- → Hand tools, medical implants, surgical instruments, cutting tools





The patented ISF<sup>®</sup> process (chemically accelerated mass finishing) is based on proven components from mass finishing technology.

Reactive ISF<sup>®</sup> compounds generate a thin oxide layer (black mode) on the surface of the component. Special non-abrasive ceramic media wipes the film from the part's surface.



Peaks on parts are removed without metal removal in the valleys, thus leveling and smoothing the parts surface down to Ra =  $0.02 \,\mu m$  (Ra =  $0.8 \,\mu inch$ ), Rz =  $0.2 \,\mu m$  (Rz =  $8 \,\mu inch$ ).

The ISF® process is then followed by a burnishing step.

- by
  reducing running noise, friction heat and wear, energy consumption and operating costs
- extending service intervals and overall component life
- allowing the design of lighter weight components

## A finish that convinces

- Surface roughness levels as low as Ra = 0.02 μm (Ra = 0.8 μinch), Rz = 0.2 μm (Rz = 8 μinch).
- Contact area with increased load capacity
- Components geometry maintained
- ➡ Surfaces free of abrasive contamination
- ➡ Matte to high-gloss surface finishes

measurement-conditions		parameter			
measurement-cond. tracing pin type / measured section/ speed / cut off filter / measured values /	TK50 3200 μ" 0.060 "	Rmax      129.65 µin        Rk      62.60 µin        Rsk      -0.321        Rvk      32.36 µin        Rpk      16.06 µin        Rz      117.65 µin	Rmr01(0.100µ") Rmr03(0.200µ") Rmr03(0.500µ") Rmr04(1.000µ") Rmr05(1.200µ") Rmr05(2.000µ") Rmr02(60.0 %) Rmr03(75.0 %) Rmr03(75.0 %) Rmr05(90.0 %) Rmr06(100.0 %)	5.1 9 5.4 9 5.6 9 5.8 9 6.5 9 35.83 µi 42.13 µi 51.97 µi 55.91 µi 66.93 µi 110.24 µi	
R-	Filter ISO 11	562(M1) Lc = 0.010 "			
50.0				· · · · · ·	

### Surface roughness before the ISF® process

measurement-conditions		parameter						
measurement-cond. tracing pin type / measured section/ speed / cut off filter / measured values /	TK50 3200 µ" 0.060 " 0.006 "/sec 0.010 " ISO 11562(N 8000	Ra Rmax Rk Rsk Rvk Rpk Rz	16.34 µin 3.54 µin -0.964 3.94 µin 3.20 µin	Rmr01(0.100µ")        Rmr02(0.200µ")        Rmr03(0.500µ")        Rmr04(1.000µ")        Rmr05(1.200µ")        Rmr01(50.0 %)        Rmr02(60.0 %)        Rmr03(75.0 %)        Rmr03(75.0 %)        Rmr05(1.00 %)        Rmr05(0.0 %)	6.0 % 6.0 % 7.4 % 10.9 % 33.5 % 2.76 µir 3.54 µir 3.54 µir 3.94 µir 14.57 µir			
R- Filter ISO 11562(M1) Lc = 0.010 "								
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Surface roughness after the ISF <sup>®</sup> process

